



## **PSM Alert**

### **OSHA Chemical Facility National Emphasis Program (NEP) for Process Safety Management (PSM) is now Issued Nationwide November 30, 2011**

**What Can You Expect?**

**Are You Ready?**

*Presented by*  
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**Date:** January 25, 2012

**Time:** 2:00–3:00 pm Eastern Time

**Cost:** \$120.00

**CEU Credits:** 0.1 CEU Credits\*

**[Registration Information Below]**

#### **Webinar Overview**

The new Chemical Facility National Emphasis Program, NEP establishes policies and procedures for inspecting facilities nationwide that are covered by OSHA's process safety management (PSM) standard. This 60 minute webinar will review the key aspects of the Chemical Facility NEP, the unique differences from previous NEPs addressing compliance with PSM, what to expect if your facility winds up on the inspection list, lessons learned from both the facility and OSHA perspectives, and the necessary steps to take in order to prepare for a NEP inspection.

#### **Benefits of Participation**

After participating in the webinar, participants will have an overall understanding of the Chemical Facility NEP, who it applies to, OSHA's implementation plan, what to expect during an NEP inspection, how to assess current compliance and steps necessary to develop a NEP compliance plan.

#### **Webinar Outline**

- What's it all about – Chemical Facility NEP Overview
- OSHA's Strategy
- What We've Learned from OSHA's NEP Initiatives
- What's Necessary to Ensure Compliance – Management System Basics
- How to Get Ready – Developing a NEP Compliance Plan

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To register for the webinar **click here:** [Register and Pay](#)

Upon registration, webinar log-in information will be emailed to you.

\*0.1 CEU Credits may be applied following a completion and passing grade of a quiz and completion of Evaluation Feedback Form.

*No refunds will be issued once registered. Credit may be arranged.*